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Secondary organic aerosol formation from \textit{m}-xylene, toluene, and benzene

N. L. Ng\textsuperscript{1}, J. H. Kroll\textsuperscript{1,*}, A. W. H. Chan\textsuperscript{1}, P. S. Chhabra\textsuperscript{1}, R. C. Flagan\textsuperscript{1}, and J. H. Seinfeld\textsuperscript{1}

\textsuperscript{1}Departments of Chemical Engineering and Environmental Science and Engineering, California Institute of Technology, Pasadena, CA 91125, USA
*current address: Aerodyne Research, Inc. 45 Manning Road, Billerica, MA 01821, USA

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Correspondence to: J. H. Seinfeld (seinfeld@caltech.edu)
Abstract

Secondary organic aerosol (SOA) formation from the photooxidation of \( m \)-xylene, toluene, and benzene is investigated in the Caltech environmental chambers. Experiments are performed under two limiting NO\(_x\) conditions; under high-NO\(_x\) conditions the peroxy radicals (RO\(_2\)) react only with NO, while under low-NO\(_x\) conditions they react only with HO\(_2\). For all three aromatics studied (\( m \)-xylene, toluene, and benzene), the SOA yields (defined as the ratio of the mass of organic aerosol formed to the mass of parent hydrocarbon reacted) under low-NO\(_x\) conditions substantially exceed those under high-NO\(_x\) conditions, suggesting the importance of peroxy radical chemistry in SOA formation. Under low-NO\(_x\) conditions, the SOA yields for \( m \)-xylene, toluene, and benzene are constant (36%, 30%, and 37%, respectively), indicating that the SOA formed is essentially nonvolatile. Under high-NO\(_x\) conditions, aerosol growth occurs essentially immediately, even when NO concentration is high. The SOA yield curves exhibit behavior similar to that observed by Odum et al. (1996, 1997a, b), although the values are somewhat higher than in the earlier study. The yields measured under high-NO\(_x\) conditions are higher than previous measurements, suggesting a “rate effect” in SOA formation, in which SOA yields are higher when the oxidation rate is faster. Experiments carried out in the presence of acidic seed aerosol reveal no change of SOA yields from the aromatics as compared with those using neutral seed aerosol.

1 Introduction

Aromatic hydrocarbons contribute an important fraction (~20–30%) of total volatile organic compounds in the urban atmosphere (Calvert et al., 2002). Atmospheric oxidation of aromatic hydrocarbons leads to the production of ozone as well as low-volatility species which then partition into the condensed phase, forming secondary organic aerosol (SOA).

The anthropogenic contribution to global SOA formation is currently estimated to be
small, roughly about 10% (Tsiganidis and Kanakidou, 2003). Ambient measurements
suggest that SOA formation in the atmosphere is higher than that predicted by cur-
rent models (Heald et al., 2005, 2006; de Gouw et al., 2005; Volkamer et al., 2006).
In addition, it has been suggested that SOA formation from anthropogenic sources
is substantially higher than currently thought (de Gouw et al., 2005; Volkamer et al.,
2006).

Gas-phase chemistry of aromatic hydrocarbons is dominated by reaction with the
OH radical (Calvert et al., 2002). Despite considerable study of the oxidation chem-
istry of aromatic hydrocarbons, the basic underlying mechanisms of SOA formation
and growth from aromatic precursors remain poorly understood. There have been few
studies on the molecular composition of SOA from aromatic hydrocarbons (Forstner et
al., 1997; Jang and Kamens, 2001; Kleindienst et al., 2004). The carbon balance is
poorly constrained; generally, only about 50% of the reacted carbon has been identified
as products (Calvert et al., 2002).

SOA formation from individual precursors is typically studied in laboratory chamber
experiments. Aerosol yields from the photooxidation of aromatic hydrocarbons have
been shown to be highly sensitive to the NOx level (Hurley et al., 2001; Johnson et al.,
2004, 2005; Song et al., 2005); generally, a higher SOA yield is observed under low-
NOx conditions. This general dependence of SOA formation on the NOx level has been
proposed to be the result of differences in concentrations of different oxidants (OH, O3,
and NO3) (Hurley et al., 2001), or in changes in peroxy radical chemistry (Hatakeyama
et al., 1991; Johnson et al., 2004, 2005; Presto et al., 2005; Kroll et al., 2006). In
addition, particle-phase reactions have been found to be important processes in SOA
formation (Kalberer et al., 2004; Gao et al., 2004a, b; Tolocka et al., 2004), and the
presence of sulfuric acid seed has been shown to lead to increased SOA yields in a
number of systems (Jang et al., 2002; linuma et al., 2004; Gao et al., 2004a, b; Edney
et al., 2005). Odum et al. (1996, 1997a, b) performed an extensive study on aromatic
SOA formation. In light of the recent findings on the NOx dependence and effect of
seed aerosol acidity on SOA yields, it is important that SOA formation from aromatics
be restudied to establish fully the NO$_x$ dependence and effect of particle acidity on SOA formation.

Most chamber experiments of SOA formation by aromatics involve the irradiation of aromatic/NO$_x$ mixtures (Izumi and Fukuyama, 1990; Odum et al., 1996, 1997a, b; Hurley et al., 2001; Johnson et al., 2004; Song et al., 2005). In these classical photooxidation experiments, the NO$_x$ level in the chamber constantly changes, making it difficult to isolate the effect of NO$_x$ on SOA formation. For example, the decreasing NO concentration over the course of the experiment may lead to a switch from “high-NO$_x$” conditions to “low-NO$_x$” conditions for the peroxy radical chemistry (Johnson et al., 2004). Another potential complication in interpreting SOA data is that a delay in aerosol formation from the onset of photooxidation has been frequently observed in aromatic systems; in particular, aerosol does not form until the concentration of NO approaches zero. When extrapolating to urban areas where the NO$_x$ level is usually high, this would suggest that aromatics (and other hydrocarbons) do not produce SOA in the atmosphere. The observation that SOA does not form until [NO] approaches zero is not universal, however; in a study of toluene photooxidation by Stroud et al. (2004), aerosol growth is observed even at NO concentrations of 1–3 ppm. Thus the NO$_x$ dependence of SOA yields, which is a crucial parameter for atmospheric modeling, is very poorly understood.

In this work, SOA formation from the photooxidation of $m$-xylene, toluene, and benzene is investigated. A main goal of this study is to establish the NO$_x$ dependence of SOA formation for these aromatic hydrocarbons. In the experiments, SOA formation under two NO$_x$ conditions is studied: (1) high-NO$_x$ experiments in which HONO is used as the OH precursor and the initial NO$_x$ is $\sim$1 ppm; and (2) low-NO$_x$ experiments in which H$_2$O$_2$ is used as the OH precursor and the initial NO$_x$ is $\leq$1 ppb. By performing experiments at these extreme NO$_x$ limits, the oxidation conditions (initiating oxidant and fate of peroxy radicals) can be maintained relatively constant over the course of the experiment, allowing for the evaluation of the effect of NO$_x$ level on SOA formation. Additionally, the effect of seed aerosol acidity on SOA formation is studied.
under both high- and low-NO$_x$ conditions. The SOA yield parameters obtained at the two NO$_x$ limits allow one to parameterize the NO$_x$ dependence of SOA formation for use in atmospheric models (Presto et al., 2006).

2 Experimental Section

Experiments are performed in Caltech’s indoor, dual 28 m$^3$ Teflon environmental chambers. Details of the facilities have been given elsewhere (Cocker et al., 2001; Keywood et al., 2004). Before each experiment, the chambers are flushed continuously with dry purified air for $\sim$24 h. Each chamber has a dedicated Differential Mobility Analyzer (DMA, TSI model 3081) coupled with a condensation nucleus counter (TSI model 3760) for measuring aerosol size distribution, number concentration, and volume concentration. All aerosol growth data are corrected for wall loss, in which size-dependent coefficients determined from inert particle wall loss experiments are applied to the aerosol volume data (Keywood et al., 2004). Temperature, relative humidity (RH), O$_3$, NO, and NO$_x$ are continuously monitored. Half of the available black lights are used in the experiments. The initial temperature of the experiment is 20°C; over the course of an experiment, heating from the lights leads to a temperature increase of $\sim$5°C inside the chambers.

Seed particles are introduced into the chamber to act as a substrate onto which the gas-phase products may condense. In an earlier work, we have shown that without seed particles, there is an “induction period” in which hydrocarbon is reacted but no aerosol is formed, which has the effect of biasing SOA yield measurements low (Kroll et al., 2007). Therefore, for all experiments in this study seed particles are used to eliminate this effect. Seed particles are generated by atomizing an aqueous solution with a constant-rate atomizer. The nonacid seed consists of 0.015 M (NH$_4$)$_2$SO$_4$, while the acidic seed contains a mixture of 0.015 M (NH$_4$)$_2$SO$_4$ and 0.015 M H$_2$SO$_4$. Since all experiments are performed at RH$\sim$5%, which is lower than the crystallization RH (35%) of ammonium sulfate, the nonacid seed is likely a solid (Seinfeld and Pandis,
The initial particle number concentration is about 30 000 particles cm$^{-3}$, with a geometric mean diameter of about 50 nm. Initial aerosol seed volume is about 15 µm$^3$ cm$^{-3}$. After introduction of the seed aerosol, a known volume of the parent hydrocarbon is injected into a glass bulb, and introduced into the chambers by an air stream. The concentration (mixing ratio) of the parent hydrocarbon is monitored with a Hewlett Packard gas chromatograph (model 5890) with flame ionization detection (GC-FID).

In most of the high-NO$_x$ experiments nitrous acid (HONO) serves as the OH precursor. It is introduced into the chamber after injection of the seed aerosol and parent hydrocarbon. HONO is prepared by dropwise addition of 15 mL of 1% NaNO$_2$ into 30 mL of 10% H$_2$SO$_4$ in a glass bulb. The bulb is then attached to the chamber and a stream of dry air is passed through the bulb into the chamber. NO and NO$_2$, formed as side products in the preparation of HONO, are also introduced into the chamber, and are measured by a commercial NO$_x$ monitor (Horiba APNA-360, Irvine, CA). Additional NO from a 500 ppm gas cylinder (Scott Marrin, Inc.) is introduced into the chamber after the addition of HONO to achieve a total NO$_x$ level in the chamber of about 1 ppm (detection limit of the NO$_x$ monitor). In some high-NO$_x$ experiments, only NO and NO$_2$ (from gas cylinders) are added to the chamber. To differentiate these experiments from the high-NO$_x$ experiments in which HONO is used as the OH precursor, we refer to these experiments as classical photooxidation experiments. The majority of the high-NO$_x$ experiments in this study are performed with HONO; only a few classical photooxidation experiments are performed for comparison purposes.

For low-NO$_x$ experiments, H$_2$O$_2$ is used as the OH precursor. The background NO$_x$ level in the chamber during the experiment is <1 ppb. H$_2$O$_2$ is introduced into the chamber (prior to introduction of seed particles and parent hydrocarbon) by bubbling air through a 50% H$_2$O$_2$ solution for 2.5 h at 5 L/min. The air stream then passes through a particle filter to remove any droplets. The concentration of H$_2$O$_2$ in the chamber is not measured; based on the rate of hydrocarbon decay we estimate [H$_2$O$_2$] to be ∼3–5 ppm (Kroll et al., 2006).

Once the seed, parent hydrocarbon, and NO$_x$ concentrations stabilize, reaction is
initiated by irradiating the chamber with blacklights. Output from the lights is between 300 and 400 nm, with a maximum at 354 nm. At these wavelengths HONO efficiently photolyzes to OH and NO. By contrast H₂O₂ absorbs only weakly in this wavelength range, requiring the use of ppm concentrations of H₂O₂ to achieve reasonable levels of OH.

The parent aromatics studied (shown in Table 1) and their stated purities are as follows: m-xylene (Aldrich, anhydrous, 99+%), toluene (Aldrich, anhydrous, 99.8%), and benzene (Aldrich, anhydrous, 99.8%). Experimental conditions and results for high-NOₓ and low-NOₓ experiments are given in Tables 2 and 3, while those for studying the effect of seed acidity on SOA growth are given in Table 4. In calculating SOA yield (defined as the ratio of the mass of organic aerosol formed to the mass of parent hydrocarbon reacted), knowledge of the SOA density is required. By comparing volume distributions from the DMA and mass distributions from an Aerodyne quadrupole Aerosol Mass Spectrometer (AMS), the effective densities for the SOA formed can be estimated (Bahreini et al., 2005). The estimated densities of the SOA formed from different systems are given in Table 5.

3 Results

3.1 High-NOₓ conditions

Figure 1 shows a typical reaction profile under high-NOₓ conditions in which HONO is used as the OH precursor. In this experiment, 89 ppb of m-xylene is reacted, and initial NO and NO₂ concentrations are 470 ppb and 473 ppb, respectively. The efficient photolysis of HONO generates high concentrations of OH (∼3×10⁷ molecules cm⁻³ initially), leading to a rapid hydrocarbon decay. This decay slows down after ∼1 h, suggesting that the HONO is consumed and OH radicals are instead generated through recycling via NOₓ/HOₓ chemistry. Aerosol growth occurs essentially immediately, even when [NO] is high (100’s of ppb). With the high NO concentration, formation of ozone
Concentration (mixing ratio) profiles from two classical photooxidation experiments with different initial NO\textsubscript{x} concentrations are shown in Fig. 2. Figure 2a shows the reaction profile from the photooxidation of 101.6 ppb \textit{m}-xylene, with initial NO and NO\textsubscript{2} concentrations of 97 ppb and 26 ppb, respectively. The hydroxyl radical source in classical photooxidation experiments is likely from the photolysis of HONO, which is formed from the heterogeneous reaction of NO\textsubscript{2} on the chamber wall. The \textit{m}-xylene-OH reaction leads to formation of RO\textsubscript{2} radicals, which react with NO rapidly, converting NO to NO\textsubscript{2}. Ozone is formed from the photolysis of NO\textsubscript{2}, with its concentration increasing rapidly when [NO] falls below \textasciitilde 50 ppb. Only when the NO concentration approaches zero does aerosol growth begin, consistent with other classical photooxidation experiments (Izumi and Fukuyama, 1990; Hurley et al., 2001; Johnson et al., 2004; Martin-Revíejo and Wirtz, 2005; Song et al., 2005). The difference between high-NO\textsubscript{x} experiments and classical photooxidation experiments will be discussed in Sect. 4.2. Figure 2b shows the reaction profile for the photooxidation of 94.8 ppb \textit{m}-xylene, with initial NO and NO\textsubscript{2} concentrations of 878 ppb and 65 ppb, respectively. The NO concentration decreases over the course of the experiment, but does not fall below 100 ppb, even after 20 h. A negligible amount of ozone is formed during the experiment, and no SOA is formed.

For \textit{m}-xylene and toluene, a series of high-NO\textsubscript{x} experiments (HONO experiments) with varying initial hydrocarbon concentrations are carried out. The time-dependent “growth curves” (organic aerosol $\Delta M_o$ as a function of hydrocarbon reacted $\Delta HC$) over the course of the experiment, for four \textit{m}-xylene experiments, with initial hydrocarbon concentrations ranging from 42 to 172 ppb, are shown in Fig. 3. In these experiments, 67–79\% of the initial \textit{m}-xylene is consumed. Most of the parent hydrocarbon is consumed in the first hour and the maximum aerosol yield is reached. After that hydrocarbon continues to decay slowly and there is little or no SOA growth, as a result the aerosol yield decreases. Only SOA growth data up to the maximum aerosol yield are shown.

The time-dependent growth curves for four toluene experiments are shown in Fig. 4.
The initial toluene concentration ranges from 88 to 270 ppb. Since the toluene-OH reaction rate constant is \( \sim 4 \) times lower than that of \( m \)-xylene-OH, more initial toluene is needed relative to \( m \)-xylene; only about 30–37% of the initial toluene injected is consumed at the point of maximum aerosol yield. Photooxidation of toluene under high-NO\(_x\) conditions results in slightly more SOA growth than for \( m \)-xylene.

Because benzene reacts slowly with OH radicals (\( k = 1.22 \times 10^{-12} \) cm\(^3\) molecule\(^{-1}\) s\(^{-1}\), Calvert et al., 2002), it is not feasible to carry out photooxidation experiments over a range of initial benzene concentrations unless high levels (ppm) of benzene are used. Thus only a single benzene photooxidation experiment at high NO\(_x\) was carried out; at an initial benzene concentration of 337 ppb, only 12% is reacted at the point of maximum aerosol yield. The time-dependent growth curve from benzene under high-NO\(_x\) conditions (as well as under low-NO\(_x\) conditions) is shown in Fig. 5.

### 3.2 Low-NO\(_x\) conditions

Under low-NO\(_x\) conditions, aerosol growth is observed immediately after initiation of irradiation. The parent hydrocarbon decays at a much slower rate than under high-NO\(_x\) conditions, due to the slow production of OH radicals by H\(_2\)O\(_2\) photolysis and lack of OH regeneration by NO\(_x\)/HO\(_x\) cycling. As OH radicals are continually produced, the OH concentration is constant throughout the experiment \( (\sim 3 \times 10^6 \) molecules cm\(^{-3}\)). Ozone formation of \( \sim 10–15 \) ppb is observed, possibly owing to residual material released from the chamber walls.

Time-dependent growth curves for four \( m \)-xylene low-NO\(_x\) experiments are shown in Fig. 6, with initial \( m \)-xylene concentrations ranging from 9 to 37 ppb. About 83–89% of the initial hydrocarbon injected is consumed at the point at which the SOA yield reaches its maximum. From Fig. 6 it is clear that the SOA yield from \( m \)-xylene photooxidation is constant under low-NO\(_x\) conditions, at 36%. Since the \( m \)-xylene SOA yield is much higher under low-NO\(_x\) conditions, a smaller amount of initial parent hydrocarbon is needed to produce the same amount of SOA than under high-NO\(_x\) conditions.
Comparable time-dependent growth curves for four toluene low-NO\textsubscript{x} experiments are shown in Fig. 7. The initial toluene concentration ranges from 21 to 140 ppb. With the slower reactivity of toluene relative to \textit{m}-xylene, only about 45–48\% of the initial toluene is consumed. As with \textit{m}-xylene, the aerosol yield (30\%) is substantially higher than under high-NO\textsubscript{x} conditions.

The time-dependent growth curve for benzene photooxidation is shown in Fig. 5. Similar to \textit{m}-xylene and toluene, benzene photooxidation under low-NO\textsubscript{x} conditions results in a constant SOA yield (37\%).

3.3 SOA yield parameters

SOA yield has traditionally been described by a semi-empirical model based on absorptive gas-particle partitioning of two semivolatile products (Odum et al., 1996, 1997a, b):

\[
Y = \Delta M_o \left[ \frac{\alpha_1 K_{om,1}}{1 + K_{om,1} M_o} + \frac{\alpha_2 K_{om,2}}{1 + K_{om,2} M_o} \right]
\]  

in which \( Y \) is the aerosol yield, \( \Delta M_o \) is the organic aerosol mass produced, \( M_o \) is the organic aerosol mass present (equal to \( \Delta M_o \) in chamber experiments with no absorbing organic mass present initially), \( \alpha_i \) is the mass-based gas-phase stoichiometric fraction for semivolatile species \( i \), and \( K_{om,i} \) is the gas-particle partitioning coefficient for species \( i \). With this two-product model, Eq. (1) can be fit to experimental yield data to determine values for \( \alpha_i \) and \( K_{om,i} \), and the resulting plot (\( Y \) versus \( M_o \)) is generally referred to as a “yield curve”.

For \textit{m}-xylene and toluene, the final SOA yield for each high-NO\textsubscript{x} (HONO) experiment is calculated, and the data are fitted to Eq. (1) to obtain the SOA yield parameters. The high-NO\textsubscript{x} yield curves for \textit{m}-xylene and toluene are shown in Fig. 8. For all three aromatics (\textit{m}-xylene, toluene, and benzene), the low-NO\textsubscript{x} experiments result in a constant aerosol yield (the slope of the “growth curve”), implying the SOA formed can be represented by a single product with very low volatility. Under these conditions the yield
curve is simply a horizontal line, and the constant yield corresponds to $\alpha_1$ in Eq. (1). SOA growth parameters for the three compounds under high-NO$_x$ and low-NO$_x$ conditions are summarized in Table 6.

3.4 Acid/nonacid seed experiments

Several $m$-xylene and toluene photooxidation experiments are performed in the presence of acid seed to study the effect of seed acidity on SOA growth. The nonacid seed consists of 0.015 M (NH$_4$)$_2$SO$_4$ while the acid seed contains 0.015 M (NH$_4$)$_2$SO$_4$ and 0.015 M H$_2$SO$_4$. The nonacid seed is solid since the experiments are performed under dry conditions (RH~5%). The pH of the acid seed is calculated with two aerosol thermodynamic models, the Aerosol Inorganic Model II (AIM) and ISORROPIA (http://mae.ucdavis.edu/~sclegg/aim.html; http://nenes.eas.gatech.edu/ISORROPIA/). The lowest RH specified in AIM is 10%, therefore this value is used as the input rather than the actual RH at which the experiments were performed (~5%). The pH calculated by AIM is –1.7. For ISORROPIA, the “reverse” model (assume aerosol-phase concentrations are known) gives a pH of 1.5, while the “forward” model (assume total (i.e. gas + aerosol) concentrations are known) gives a pH of 1.7. The large difference in the pH values calculated by the two models is likely a result of the uncertainty of the calculation at the high ionic strength corresponding to low RH.

Growth curves for toluene photooxidation under acidic and nonacid conditions are shown in Fig. 9. Regardless of the NO$_x$ level, the time-dependent growth curves from the acid and nonacid experiments are essentially indistinguishable. Therefore, there is no evidence that the presence of acidic seed enhances SOA growth in the photooxidation of toluene; similar results are observed for $m$-xylene.
4 Discussion

4.1 Effect of NO\textsubscript{x} on SOA yields

Experiments have been performed under two limiting NO\textsubscript{x} conditions: (1) high-NO\textsubscript{x} experiments in which HONO is used as the OH precursor; and (2) low-NO\textsubscript{x} experiments in which H\textsubscript{2}O\textsubscript{2} is used as the OH precursor. For all hydrocarbons, considerably more SOA is formed under low-NO\textsubscript{x} than high-NO\textsubscript{x} conditions (Figs. 3–7). Under high-NO\textsubscript{x} conditions, the SOA yields from \textit{m}-xylene and toluene photooxidation are about 10%; they are 36% and 30%, respectively, under low-NO\textsubscript{x} conditions. Similar NO\textsubscript{x} dependences have been observed in other SOA-forming systems (Hatakeyama et al., 1991; Zhang et al., 1992; Hurley et al., 2001; Johnson et al., 2004; Song et al., 2005; Presto et al., 2005; Kroll et al., 2006). Since O\textsubscript{3} and NO\textsubscript{3} are not formed appreciably under either set of conditions, oxidation is dominated by OH radicals for all experiments, so this NO\textsubscript{x} effect cannot be a result of differences in relative oxidant levels (Hurley et al., 2001). Instead the NO\textsubscript{x} level likely governs the fate of the organic peroxy radicals formed subsequent to the hydrocarbon-OH reaction, which in turn controls the volatility of molecular products and hence the amount of SOA formed.

Shown in Fig. 10 is the simplified mechanism of the initial steps of toluene-OH reaction, leading to the formation of condensable products. One mechanism by which NO\textsubscript{x} levels may affect the products formed in the oxidation of aromatic hydrocarbons is by reaction with the aromatic-OH adduct. Under atmospheric conditions, such radicals react with O\textsubscript{2}, but under very high levels of NO\textsubscript{x} (as is often the case in chambers), the adduct + NO\textsubscript{2} reaction increases in importance, leading to nitrogen-containing ring-retaining products such as nitrobenzene and nitrotoluene (Atkinson et al., 1989; Atkinson and Aschmann, 1994). In the current work, photooxidation of \textit{m}-xylene and toluene is carried out in the presence of ~500 ppb each of NO and NO\textsubscript{2}; while for photooxidation of benzene the initial NO\textsubscript{2} concentration is <100 ppb. At these NO\textsubscript{x} levels, the reaction of the aromatic-OH adduct with NO\textsubscript{2} is not expected to be significant, so such reactions cannot be responsible for the observed effect of NO\textsubscript{x} on SOA yield.
Reaction of the aromatic-OH adduct with O$_2$ results in the formation of peroxy radicals. Theoretical studies have shown that the peroxy radicals preferentially cyclize to form bicyclic radicals, which then react with O$_2$ to form bicyclic peroxy radicals (Andino et al., 1996; Lay et al., 1996; Suh et al., 2003; Fan et al., 2006). As is typical for RO$_2$ radicals, the fate of the bicyclic peroxy radicals depends mainly on the relative concentrations of NO, HO$_2$, and RO$_2$. At the two limiting NO$_x$ conditions of this study, the peroxy radical chemistry is straightforward; under high-NO$_x$ conditions, RO$_2$ reacts virtually entirely with NO, as NO concentration is high throughout the entire experiment, while under low-NO$_x$ conditions, RO$_2$ reacts predominantly with HO$_2$. Based on the Master Chemical Mechanism version 3.1 (MCM v 3.1, http://www.chem.leeds.ac.uk/Atmospheric/MCM/mcmproj.html), a simple kinetic simulation shows that under low-NO$_x$ conditions, the RO$_2$+RO$_2$ reaction accounts for less than 1% of the RO$_2$ reacted because of the relative reaction rate constants ($k_{RO_2+RO_2}=8.8\times10^{-13}$ cm$^3$ molecule$^{-1}$ s$^{-1}$, $k_{RO_2+HO_2}=2.3\times10^{-11}$ cm$^3$ molecule$^{-1}$ s$^{-1}$) as well as the high HO$_2$ concentration. Thus the larger SOA yields obtained under low-NO$_x$ conditions imply that the products formed via the RO$_2$+HO$_2$ partition much more readily into the aerosol phase than those formed via the RO$_2$+NO reaction. This conclusion is the same as that reached by previous studies (Hatakeyama et al., 1991; Johnson et al., 2004, 2005; Presto et al., 2005; Kroll et al., 2006). That SOA yields are constant under low-NO$_x$ conditions implies that the SOA formed by this channel is essentially nonvolatile.

In the classical photooxidation experiments carried out in this study and by other researchers (Izumi and Fukuyama, 1990; Hurley et al., 2001; Johnson et al., 2004; Martin-Revíejo and Wirtz, 2005; Song et al., 2005), an “induction period”, a delay between the onset of oxidation and SOA formation, was observed. This too is a likely result of the role of NO$_x$ in peroxy radical chemistry, and hence in product volatility and SOA formation. As illustrated in Fig. 2a, only when [NO] approaches zero does aerosol growth commence. As [NO] approaches zero (from the RO$_2$+NO and HO$_2$+NO reactions with O$_2$), the peroxy radicals are more likely to cyclize to form bicyclic peroxy radicals, which then react with HO$_2$ to form bicyclic radicals.
reactions), the RO₂+HO₂ reaction starts to compete with the RO₂+NO reaction. The fraction of RO₂ which reacts with HO₂, k_{RO₂+HO₂}[HO₂]/(k_{RO₂+NO}[NO]+k_{RO₂+HO₂}[HO₂]), can be calculated based on the rate reaction rate constants (k_{RO₂+HO₂}= 2.3×10^{-11} \text{ cm}^3 \text{ molecule}^{-1} \text{ s}^{-1}; k_{RO₂+NO}= 8.5×10^{-12} \text{ cm}^3 \text{ molecule}^{-1} \text{ s}^{-1}) (MCM v 3.1). For instance, at ~1 ppb of NO, it only requires 42 ppt of HO₂ for 10% of the RO₂ to react via RO₂+HO₂. Thus it is likely that initial SOA formation results from the RO₂ + HO₂ reaction, consistent with the simulations of SOA formation from classical photooxidation experiments of toluene (Johnson et al., 2004). To further study the role of peroxy radical chemistry in the “induction period”, in one of the experiments additional NO was injected after its initial consumption. SOA growth slows down immediately. This provides strong evidence that the presence of NO suppresses the formation of nonvolatile hydroperoxides (and hence further particle-phase reactions of hydroperoxides) from the RO₂+HO₂ reaction and results in a lower SOA yield (Johnson et al., 2004, 2005).

The time-dependent growth curves for benzene photooxidation under high- and low-NOₓ conditions exhibit the same trend as that of m-xylene and toluene, in which more SOA is formed under low-NOₓ conditions. Martin-Reviejo and Wirtz (2005) studied the formation of SOA from benzene photooxidation under different NOₓ conditions. However, as the NOₓ dependence of SOA formation was not systematically studied, it is difficult to draw a definite conclusion on the effect of NOₓ on SOA yields from their data. Additionally, the experimental conditions are somewhat different; in particular, the experiments in that study were performed in the absence of seed aerosol while in the current work ammonium sulfate seed aerosol is employed. Kroll et al. (2007) find that SOA yields from the photooxidation of aromatic hydrocarbons are lower when inorganic seed particles are not present initially. The absence of seed particles results in a period in which the hydrocarbon is reacted but no aerosol is formed. The length of the “seed induction period” (and hence the amount of hydrocarbon reacted in this period, ΔHC) is likely to be affected by the NOₓ levels. Thus the aerosol yields (ΔM₀/ΔHC) obtained by Martin-Reviejo and Wirtz (2005) under different NOₓ conditions may be affected by this “seed induction period” and cannot be directly compared.
4.2 Effect of oxidation rate

In contrast to the classical photooxidation experiments, under high-NO$_x$ conditions, SOA formation is observed even when [NO] is several hundreds of ppb (Fig. 1), suggesting that RO$_2$+NO reactions can indeed form condensable products. This can be seen directly by comparing Fig. 1 (HONO) with Fig. 2b (classical). In both cases, the initial $m$-xylene concentration and NO$_x$ concentration are about 100 ppb and 1 ppm, respectively. However, while SOA is formed immediately after photooxidation commences in the HONO experiment, no SOA growth is observed in the classical photooxidation experiment. HONO photolysis is an efficient source of OH in the wavelength range of our blacklights; thus there is a surge of OH once the lights are turned on, resulting in a rapid rate of $m$-xylene oxidation. In the classical photooxidation experiment, OH is generated mainly from recycling through NO$_x$ and HO$_x$ cycles, and OH concentrations are generally far lower than in the HONO experiments. The large difference between these two cases suggests that SOA yields are dependent on the oxidation rate, with faster oxidation rates resulting in higher SOA yields.

This “rate effect” could arise as a result of loss of semivolatiles through processes other than the simple formation and partitioning of semivolatile organics. The loss of semivolatiles has been proposed as one of the mechanisms for higher SOA yields observed from aromatic photooxidation in the presence of seed aerosols as compared to nucleation experiments (Kroll et al., 2007). In the mechanism shown in Fig. 10, X represents the generic non particle-phase product of all gas-phase loss processes. Possibilities include loss of organic species to the chamber walls, photolysis, and further reactions to form volatile products. With a rapid oxidation rate, the gas-phase concentration of semivolatiles increases quickly, and the high concentrations of semivolatiles ensure that aerosol growth ensues even in the presence of semivolatile loss processes (i.e. paths not forming SOA). On the other hand, the slower formation of semivolatiles in the presence of semivolatile sinks leads to less SOA growth. If the dominant loss of semivolatiles is deposition to the chamber walls, then conditions in which the effect
of wall loss is minimized (i.e., when the reaction is fastest) are expected to be most representative of atmospheric SOA formation.

The observed formation of SOA under high-NO\textsubscript{x} conditions is consistent with the study by Stroud et al. (2004), in which the photooxidation of toluene resulted in SOA growth despite the high NO concentration throughout the experiment. According to the simulations by Johnson et al. (2004), the ppm level of NO\textsubscript{x} employed by Stroud et al. (2004) should entirely suppress SOA formation. The rate effect could resolve this discrepancy: the use of isopropyl nitrite as an OH source in the study by Stroud et al. (2004) facilitates a rapid oxidation rate of toluene, leading to SOA formation despite the presence of high levels of NO. This suggests a missing sink of semivolatiles (possibly wall loss) in the detailed simulations of Johnson et al. (2004).

The rate effect also can explain higher SOA yields in the high-NO\textsubscript{x} experiments (HONO) compared to the classical photooxidation experiments (Odum et al., 1996) (Fig. 11). Several classical photooxidation experiments with similar NO\textsubscript{x} levels as in Odum et al. (1996) were performed in the present study, with SOA yields comparable to those of Odum et al. (1996). The yield curve from Odum et al. (1996) has been adjusted based on the temperature (25°C) and SOA density (1.48 g cm\textsuperscript{-3}) obtained in this study. The NO\textsubscript{x} concentrations (several hundreds of ppb) used by Odum et al. (1996) are lower than those in the current experiments (∼1 ppm). The higher SOA yields obtained here suggest that the enhancement in SOA yield from a faster oxidation rate is greater than the suppression in SOA yield at a higher NO\textsubscript{x} concentration. This competition between the NO\textsubscript{x} effect and the rate effect may also explain the observed maximum in SOA yields as a function of NO\textsubscript{x} from isoprene photooxidation (Kroll et al., 2006).

The pair of experiments (Fig. 1 and Fig. 2b) also provides insight into the extent to which the hydrocarbon/NO\textsubscript{x} (HC/NO\textsubscript{x}) ratio characterizes the NO\textsubscript{x} level in chamber experiments. Song et al. (2005), for example, report a series of classical photooxidation experiments to study the effect of HC/NO\textsubscript{x} ratio on SOA formation from \textit{m}-xylene. It was found that aerosol yields increase with increasing HC/NO\textsubscript{x} ratio (i.e. more aerosol
growth at lower NO\textsubscript{x} levels), which is consistent with the present study. However, the experiments in Fig. 1 and 2b have essentially similar HC/NO\textsubscript{x} ratios but exhibit very different SOA growth. Therefore, while the HC/NO\textsubscript{x} ratio may be a useful metric for photochemistry for experiments with similar oxidation conditions, it is less useful when comparing systems with very different oxidative conditions, as both oxidation rate and fate of peroxy radicals may differ. Given the importance of the peroxy radical in SOA formation, the NO/HO\textsubscript{2} ratio would be the more appropriate measure of different NO\textsubscript{x} levels (Kroll et al., 2006), although continuous measurement of HO\textsubscript{2} is not currently feasible.

4.3 General mechanism of SOA formation

Despite uncertainties in the detailed chemical mechanism of aromatic photooxidation beyond the initial peroxy radical chemistry, we can gain insights into the general SOA formation mechanism and growth kinetics from the shapes of the growth curves under both high-NO\textsubscript{x} and low-NO\textsubscript{x} conditions (Figs. 3–7). Such curves allow for the identification of the rate-determining steps in SOA formation (Ng et al., 2006). In cases where the initial oxidation step determines the rate of SOA formation (condensable products are first-generation, or are formed extremely rapidly after the initial oxidation), SOA is formed at the same rate of hydrocarbon oxidation, and aerosol growth ceases once the parent hydrocarbon is consumed. In this case, time-dependent growth-curves from experiments with different initial hydrocarbon concentrations would overlap, as is the case for α-pinene ozonolysis (Ng et al., 2006). On the other hand, when there are further rate-limiting steps to the formation of condensable products, there is a time lag between hydrocarbon oxidation and SOA formation and the growth curve exhibits a vertical section at the end, as is the case for the ozonolysis and photooxidation of compounds with multiple double bonds (Ng et al., 2006).

Figures 3–7 show the time-dependent growth curves for \textit{m}-xylene, toluene, and benzene photooxidation under high-NO\textsubscript{x} and low-NO\textsubscript{x} conditions. In all cases, SOA growth is observed immediately after photooxidation commences, resulting in a smooth growth
curve from the onset of oxidation. Some hydrocarbon remains unreacted by the end of these experiments. In experiments in which all the hydrocarbon is reacted (not shown), no vertical section in the growth curve is observed, indicating there is no further SOA formation after the complete consumption of the parent hydrocarbon. This indicates that the first oxidation step (oxidation of the parent hydrocarbon) governs the rate of SOA formation.

However, unlike with α-pinene ozonolysis (Ng et al., 2006), the time-dependent growth curves from experiments with different initial aromatic hydrocarbon concentrations do not overlap, and aerosol growth is not the same for a given amount of hydrocarbon reacted (ΔHC). Instead, SOA growth at a given value of ΔHC depends on the initial hydrocarbon concentration (HC₀): experiments with higher HC₀ reach a given ΔHC in a shorter time than those with smaller HC₀. At smaller HC₀, during the longer time required to reach ΔHC, the first generation products have more time to be converted to SOA. Therefore, the divergence in growth curves at different initial hydrocarbon concentrations indicates that even though the first step is the rate-limiting in SOA formation, subsequent oxidation steps also occur prior to SOA formation. While such steps affect the kinetics of SOA formation somewhat (i.e., they are not instantaneous relative to the initial step), the small differences in growth curves at different values of HC₀ indicate they are substantially faster than the initial oxidation step. The degree of divergence in growth curves is not as pronounced for low-NOₓ experiments, suggesting that this difference in rates is greater under low-NOₓ than high-NOₓ conditions. The formation of SOA by multiple oxidation steps, in which the later steps are substantially faster than the initial oxidation, is consistent with available kinetic data and current understanding of the photooxidation of aromatic hydrocarbons. In general, first-generation products of aromatic photooxidation react about an order of magnitude faster with OH than do their parent hydrocarbons (Calvert et al., 2002). For example, whereas the benzene-OH rate constant is $1.22 \times 10^{-12}$ cm$^{-3}$ molecule$^{-1}$ s$^{-1}$, the rate constant of the reaction of OH with phenol, a major first-generation reaction product, is $2.7 \times 10^{-11}$ cm$^{-3}$ molecule$^{-1}$ s$^{-1}$ (Calvert et al., 2002).
4.4 Effect of seed acidity

To our knowledge, there are no published data on the effect of seed aerosol acidity on SOA formed from the photooxidation of aromatic VOCs. As shown in Fig. 9, seed particle acidity does not enhance the SOA yield under different NO\textsubscript{x} conditions. The composition of the acid and nonacid seed particles, as well as the RH (∼5%), are the same as those previously employed in the study of isoprene SOA formation (Surratt et al., 2007); yet, an enhancement in SOA yield is observed for isoprene experiments but not for the aromatics. The chambers are maintained at RH ∼5% in this study and so the nonacid seed particles are dry, whereas for acidic seed particles some water might be present. If aerosol water is essential for the acidity effect, its absence might explain the lack of an observed effect in the current study. The dependence of SOA growth on RH is beyond the scope of this work but warrants future investigation.

5 Implication for SOA growth from aromatic hydrocarbons

We report a series of chamber experiments investigating the NO\textsubscript{x} dependence and effect of seed aerosol acidity on SOA formation from the photooxidation of aromatic compounds. High-NO\textsubscript{x} experiments are performed with HONO as the OH precursor at initial NO\textsubscript{x} of ∼1 ppm. By performing experiments with HONO, SOA is formed under truly high-NO\textsubscript{x} conditions, as the NO concentration remains high throughout the entire experiment. In low-NO\textsubscript{x} experiments, H\textsubscript{2}O\textsubscript{2} is used as the OH precursor and the initial NO\textsubscript{x} is <1 ppb. For each of the aromatic hydrocarbons studied (m-xylene, toluene, and benzene), the SOA yields under low-NO\textsubscript{x} conditions are significantly larger than those under high-NO\textsubscript{x} conditions; this is likely a result of the competition between RO\textsubscript{2}+NO and RO\textsubscript{2}+HO\textsubscript{2} reactions, similar to what has been observed in other studies (Hatakeyama et al., 1991; Johnson et al., 2004, 2005; Presto et al., 2005; Kroll et al., 2006).

In assessing the contribution of aromatic compounds to total ambient SOA, it is
important that laboratory conditions are representative of those in the atmosphere. The aromatic SOA yield parameters ($\alpha_i$ and $K_{om,i}$) currently employed in atmospheric models are those obtained by Odum et al. (1996, 1997a, b) almost a decade ago by irradiation of hydrocarbon/NO$_x$ mixtures. With the profound dependence of NO$_x$ on SOA formation, it is necessary that the effect of NO$_x$ on SOA yields be included in atmospheric models. For instance, compounds like benzene are mainly emitted in source-rich regions; with its slow reactivity, however, benzene can be transported to areas with a lower NO$_x$ level before it react substantially, resulting in a higher SOA yield than if it reacted in the immediate vicinity of its sources. By performing experiments at two extreme NO$_x$ conditions, we are able to obtain SOA yield parameters under high- and low-NO$_x$ conditions, allowing for the parameterization of the NO$_x$ dependence for atmospheric models, based upon the reactivity of organic peroxy radicals.

Finally, detailed analysis of the chemical composition of aromatic SOA will assist in unraveling the detailed aromatic SOA formation mechanism under both high and low-NO$_x$ conditions. In a forthcoming publication, the chemical composition of aromatic SOA will be explored. Since a wide array of sulfate esters are observed only when acidified inorganic seed aerosols are employed (Surratt et al., 2007), the chemical composition of the SOA formed in nonacid/acid seed experiments may also provide insights into the lack of a seed acidity effect on SOA yields in the present study.

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References


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<thead>
<tr>
<th>Parent Hydrocarbon</th>
<th>Structure</th>
<th>Formula (MW)</th>
<th>$k_{OH}$ (cm³ molec⁻¹ s⁻¹)</th>
</tr>
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<td>$m$-xylene</td>
<td><img src="image" alt="Structure" /></td>
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</tr>
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<td>toluene</td>
<td><img src="image" alt="Structure" /></td>
<td>C₇H₈(92)</td>
<td>5.63 x 10⁻¹²</td>
</tr>
<tr>
<td>benzene</td>
<td><img src="image" alt="Structure" /></td>
<td>C₆H₆(78)</td>
<td>1.22 x 10⁻¹²</td>
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</tbody>
</table>

* $a$: Rate constants were obtained from Calvert et al. (2002)
Table 2. Initial conditions and data for high-NO$_x$ (HONO) experiments.

<table>
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<tr>
<th>Expt. No.</th>
<th>Parent Hydrocarbon</th>
<th>T (K)</th>
<th>RH (%)</th>
<th>NO (ppb)</th>
<th>NO$_2$ (ppb)</th>
<th>Seed</th>
<th>ΔHC (ppb)</th>
<th>ΔM$_a$ (µg/m$^3$) $^a$</th>
<th>SOA Yield (%) $^a$</th>
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<tbody>
<tr>
<td>1</td>
<td>m-xylene</td>
<td>297</td>
<td>5.5</td>
<td>470</td>
<td>473</td>
<td>(NH$_4$)$_2$SO$_4$</td>
<td>70.9</td>
<td>18.2 ± 1.8</td>
<td>5.9 ± 0.4</td>
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<td>2</td>
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<td>5.7</td>
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<td>494</td>
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<td>4.3 ± 1.2</td>
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</tr>
<tr>
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<td>m-xylene</td>
<td>298</td>
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<td>432</td>
<td>511</td>
<td>(NH$_4$)$_2$SO$_4$</td>
<td>132.5</td>
<td>46.4 ± 3.7</td>
<td>8.0 ± 0.3</td>
</tr>
<tr>
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<td>m-xylene</td>
<td>297</td>
<td>5.1</td>
<td>431</td>
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<td>(NH$_4$)$_2$SO$_4$</td>
<td>106.1</td>
<td>36.7 ± 2.8</td>
<td>8.0 ± 0.2</td>
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<td>524</td>
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<td>30.1</td>
<td>9.1 ± 1.3</td>
<td>8.0 ± 0.7</td>
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<td>toluene</td>
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<td>11.1 ± 0.4</td>
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<td>559</td>
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<td>12.8 ± 0.4</td>
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<tr>
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<td>toluene</td>
<td>298</td>
<td>4.4</td>
<td>373</td>
<td>568</td>
<td>(NH$_4$)$_2$SO$_4$</td>
<td>50.7</td>
<td>20.9 ± 1.9</td>
<td>10.9 ± 0.5</td>
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<td>benzene</td>
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<td>5.2</td>
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<td>86</td>
<td>(NH$_4$)$_2$SO$_4$</td>
<td>39.4</td>
<td>35.4 ± 2.7</td>
<td>28.1 ± 0.9</td>
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</tbody>
</table>

$^a$: Stated uncertainties (1σ) are from scatter in particle volume measurements

$^b$: Assuming an SOA density of 1.4 g cm$^{-3}$
Table 3. Initial conditions and data for low-NO\textsubscript{x} (H\textsubscript{2}O\textsubscript{2}) experiments.

<table>
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<tr>
<th>Expt. No.</th>
<th>Parent Hydrocarbon</th>
<th>T (K)</th>
<th>RH (%)</th>
<th>Seed</th>
<th>ΔHC (ppb)</th>
<th>ΔM\textsubscript{o} (μg/m\textsuperscript{3}) \textsuperscript{a}</th>
<th>SOA Yield (%) \textsuperscript{a}</th>
</tr>
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<tbody>
<tr>
<td>1</td>
<td>m-xylene</td>
<td>298</td>
<td>5.1</td>
<td>(NH\textsubscript{4})\textsubscript{2}SO\textsubscript{4}</td>
<td>32.5</td>
<td>53.0 ± 4.2</td>
<td>37.7 ± 0.8</td>
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<tr>
<td>2</td>
<td>m-xylene</td>
<td>298</td>
<td>5.2</td>
<td>(NH\textsubscript{4})\textsubscript{2}SO\textsubscript{4}</td>
<td>16.1</td>
<td>24.6 ± 2.2</td>
<td>35.2 ± 1.8</td>
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<tr>
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<td>298</td>
<td>5.1</td>
<td>(NH\textsubscript{4})\textsubscript{2}SO\textsubscript{4}</td>
<td>8.0</td>
<td>12.8 ± 1.7</td>
<td>36.7 ± 2.6</td>
</tr>
<tr>
<td>4</td>
<td>m-xylene</td>
<td>297</td>
<td>6.2</td>
<td>(NH\textsubscript{4})\textsubscript{2}SO\textsubscript{4}</td>
<td>26.1</td>
<td>40.5 ± 3.4</td>
<td>35.7 ± 1.0</td>
</tr>
<tr>
<td>5</td>
<td>toluene</td>
<td>297</td>
<td>6.8</td>
<td>(NH\textsubscript{4})\textsubscript{2}SO\textsubscript{4}</td>
<td>32.1</td>
<td>37.4 ± 2.8</td>
<td>30.8 ± 1.7</td>
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<tr>
<td>6</td>
<td>toluene</td>
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<td>(NH\textsubscript{4})\textsubscript{2}SO\textsubscript{4}</td>
<td>63.9</td>
<td>73.1 ± 5.6</td>
<td>30.2 ± 0.7</td>
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<td>7</td>
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<td>(NH\textsubscript{4})\textsubscript{2}SO\textsubscript{4}</td>
<td>10.0</td>
<td>11.5 ± 1.6</td>
<td>30.4 ± 4.1</td>
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<td>23.8</td>
<td>26.7 ± 2.5</td>
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<tr>
<td>9</td>
<td>benzene</td>
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<td>6.6</td>
<td>(NH\textsubscript{4})\textsubscript{2}SO\textsubscript{4}</td>
<td>64.7</td>
<td>76.4 ± 5.8 \textsuperscript{b}</td>
<td>36.9 ± 0.9</td>
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\textsuperscript{a} Stated uncertainties (1σ) are from scatter in particle volume measurements
\textsuperscript{b} Assuming an SOA density of 1.4 g cm\textsuperscript{-3}
Table 4. Initial conditions and data for acid/nonacid experiments.

<table>
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<tr>
<th>Expt. No.</th>
<th>Parent Hydrocarbon</th>
<th>T (K)</th>
<th>RH (%)</th>
<th>NO_x Condition</th>
<th>Seed</th>
<th>ΔHC (ppb)</th>
<th>ΔM_o (μg/m^3)</th>
<th>SOA Yield (%)</th>
</tr>
</thead>
<tbody>
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<td>1</td>
<td>m-xylene</td>
<td>297</td>
<td>4.3</td>
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<td>60.2</td>
<td>101.3 ± 7.8</td>
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<tr>
<td>2</td>
<td>m-xylene</td>
<td>297</td>
<td>4.5</td>
<td>Low NO_x</td>
<td>(NH_4)_2SO_4 + H_2SO_4</td>
<td>58.8</td>
<td>103.5 ± 8.0</td>
<td>40.4 ± 0.6</td>
</tr>
<tr>
<td>3</td>
<td>m-xylene</td>
<td>297</td>
<td>5.0</td>
<td>High NO_x</td>
<td>(NH_4)_2SO_4</td>
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<td>78.9 ± 5.6</td>
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<td>High NO_x</td>
<td>(NH_4)_2SO_4 + H_2SO_4</td>
<td>68.5</td>
<td>78.3 ± 5.4</td>
<td>26.3 ± 0.4</td>
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<td>toluene</td>
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<td>(NH_4)_2SO_4</td>
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<td>43.8 ± 3.6</td>
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<tr>
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<td>High NO_x</td>
<td>(NH_4)_2SO_4 + H_2SO_4</td>
<td>58.2</td>
<td>38.3 ± 3.2</td>
<td>17.4 ± 0.5</td>
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</tbody>
</table>

a: low NO_x (H_2O_2 only); high NO_x (H_2O_2 + about 100 ppb NO added)
b: Stated uncertainties (1σ) are from scatter in particle volume measurements
c: Assuming SOA densities are the same as those determined for HONO experiments (see Table 5)
**Table 5.** Estimated effective SOA densities.

<table>
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<tr>
<th>Parent Hydrocarbon</th>
<th>NO\textsubscript{x} Condition</th>
<th>Effective Density (g cm\textsuperscript{-3})\textsuperscript{a}</th>
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<tbody>
<tr>
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<td>Low NO\textsubscript{x}</td>
<td>1.33 ± 0.10</td>
</tr>
<tr>
<td>m-xylene</td>
<td>High NO\textsubscript{x}</td>
<td>1.48 ± 0.10</td>
</tr>
<tr>
<td>toluene</td>
<td>Low NO\textsubscript{x}</td>
<td>1.45 ± 0.10</td>
</tr>
<tr>
<td>toluene</td>
<td>High NO\textsubscript{x}</td>
<td>1.24 ± 0.10</td>
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</tbody>
</table>

\(a\): Stated uncertainties (1\(\sigma\)) are from repeated measurements of ammonium sulfate seed densities.
Table 6. Aerosol yield parameters.

<table>
<thead>
<tr>
<th>Parent Hydrocarbon</th>
<th>NO\textsubscript{x} Condition</th>
<th>$\alpha_1$</th>
<th>$K_{om,1}$ (m\textsuperscript{3} µg\textsuperscript{-1})</th>
<th>$\alpha_2$</th>
<th>$K_{om,2}$ (m\textsuperscript{3} µg\textsuperscript{-1})</th>
</tr>
</thead>
<tbody>
<tr>
<td>$m$-xylene</td>
<td>Low NO\textsubscript{x}</td>
<td>0.30</td>
<td>N/A</td>
<td>N/A</td>
<td>N/A</td>
</tr>
<tr>
<td>$m$-xylene</td>
<td>High NO\textsubscript{x}</td>
<td>0.031</td>
<td>0.761</td>
<td>0.090</td>
<td>0.029</td>
</tr>
<tr>
<td>toluene</td>
<td>Low NO\textsubscript{x}</td>
<td>0.36</td>
<td>N/A</td>
<td>N/A</td>
<td>N/A</td>
</tr>
<tr>
<td>toluene</td>
<td>High NO\textsubscript{x}</td>
<td>0.058</td>
<td>0.430</td>
<td>0.113</td>
<td>0.047</td>
</tr>
<tr>
<td>benzene</td>
<td>Low NO\textsubscript{x}</td>
<td>0.37</td>
<td>N/A</td>
<td>N/A</td>
<td>N/A</td>
</tr>
<tr>
<td>benzene</td>
<td>High NO\textsubscript{x}</td>
<td>0.072</td>
<td>3.315</td>
<td>0.888</td>
<td>0.009</td>
</tr>
</tbody>
</table>

N/A: Not applicable
Fig. 1. Typical reaction profile of a high-NO$_x$ experiment in which HONO is used as the OH precursor (initial conditions: 89.3 ppb of $m$-xylene, 470 ppb NO, and 473 ppb NO$_2$).
Fig. 2. (a) Reaction profile of a typical classical photooxidation experiment (initial conditions: 101.6 ppb \textit{m}-xylene, 97 ppb NO, and 26 ppb NO\textsubscript{2}). (b) Reaction profile of a classical photooxidation experiment in the presence of \~1 ppm NO\textsubscript{x} (initial conditions: 94.8 ppb \textit{m}-xylene, 878 ppb NO, and 65 ppb NO\textsubscript{2}). A negligible amount of ozone is formed during the experiment, and no SOA is formed.
Fig. 3. Time-dependent growth curves for $m$-xylene photooxidation under high-NO$_x$ conditions. The concentrations in the legend refer to the amount of $m$-xylene reacted in each experiment.
**Fig. 4.** Time-dependent growth curves for toluene photooxidation under high-NO$_x$ conditions. The concentrations in the legend refer to the amount of toluene reacted in each experiment.
Fig. 5. Time-dependent growth curves for benzene photooxidation under high- and low-NO$_x$ conditions. Under high-NO$_x$ conditions, the initial benzene concentration is 337 ppb (12% reacted). Under low-NO$_x$ conditions, the initial benzene concentration is 395 ppb (16% reacted) and the system has a constant yield of 37%.
**Fig. 6.** Time-dependent growth curves for *m*-xylene photooxidation under low-NOx conditions. The concentrations in the legend refer to the amount of *m*-xylene reacted in each experiment. The system exhibits a constant yield of 36%.
Fig. 7. Time-dependent growth curves for toluene photooxidation under low-NO\textsubscript{x} conditions. The concentrations in the legend refer to the amount of toluene reacted in each experiment. The system exhibits a constant yield of 30%.
**Fig. 8.** Yield curves for toluene and \(m\)-xylene under high-NO\(_x\) conditions. The parameters for fitting the yield curves are, toluene: \(\alpha_1 = 0.058, K_{om,1} = 0.430, \alpha_2 = 0.113,\) and \(K_{om,2} = 0.047;\) \(m\)-xylene: \(\alpha_1 = 0.031, K_{om,1} = 0.761, \alpha_2 = 0.090,\) and \(K_{om,2} = 0.029.\)
Fig. 9. Time-dependent growth curves for toluene photooxidation in the presence of neutral seed versus acidic seed.
Fig. 10. A simplified SOA formation mechanism for toluene photooxidation. X represents the generic non particle-phase product from all gas-phase loss processes.
Fig. 11. Comparison of $m$-xylene high-NO$_x$ yield curve obtained in the current work to that from Odum et al. (1996). The yield curve from Odum et al. (1996) has been corrected for the temperature (25°C) of this study and density (1.48 g cm$^{-3}$) of the SOA.